Engineering properties by long range symmetry propagation initiated at perovskite heterostructure interface

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Abstract:

In epitaxial thin film systems, the crystal structure and its symmetry deviate from the bulk counterpart due to various mechanisms such as epitaxial strain and interfacial structural coupling, which induce an accompanying change in their properties. In perovskite materials, the crystal symmetry can be described by rotations of 6-fold coordinated transition metal oxygen octahedra, which are found to be altered at interfaces. Here, we unravel how the local oxygen octahedral coupling (OOC) at perovskite heterostructural interfaces initiates a different symmetry in epitaxial films and provide design rules to induce various symmetries in thin films by careful selecting appropriate

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combinations of substrate/buffer/film. Very interestingly we discovered that these combinations lead to symmetry changes throughout the full thickness of the film. Our results provide a deep insight into understanding the origin of induced crystal symmetry in a perovskite heterostructure and an intelligent route to achieve unique functional properties.

**Main text:**

Diverse electronic phases in solid state materials such as superconductivity, topological insulating phases and ferroelectricity are intimately coupled to crystal symmetry [1-5]. Controlled symmetries have been extensively employed in oxide heterostructures for generating novel properties and functionalities [6-11]. In ABO₃ perovskites, the crystal symmetry resides in the corner sharing oxygen octahedral (BO₆) network [2, 12-14]. These symmetries, or oxygen octahedral rotation (OOR) patterns in perovskite heterostructures, are usually engineered by epitaxial strain [15]. Furthermore, the required connectivity of the octahedra across the heterostructure interface enforces a geometric constraint to the 3-dimensional octahedral network in epitaxial films [16-21]. The control of this oxygen octahedral coupling (OOC) at interfaces has been shown to result in interesting phenomena in ultrathin oxide films [17-21]. However, the effect of the OOC on octahedral tilt angles decays steeply and is found to be confined to layer thicknesses of only 4-8 unit cells (uc) [17-21]. The short range impact of the OOC on the tilt angle was recently further demonstrated for La₂/3Sr₁/3MnO₃ (LSMO)/NdGaO₃ (NGO) heterostructure, in which the OOC driven novel anisotropic properties only emerge in LSMO thinner than 8 uc [17]. The limited propagation of the interface-induced
octahedral tilt into the film currently restricts the engineering of perovskite heterostructures with unique functional properties.

The rotational behavior, in-phase or out-of-phase, can still survive even when the magnitude of the octahedral tilt becomes very small. Therefore, the propagation length of the symmetry can be much larger than the propagation of an induced tilt angle. This aspect has been disregarded in the past. Here, we demonstrate and unravel the fundamentally important phenomenon of long range propagation of crystal symmetry induced by OOC in perovskite heterostructures. The symmetry of epitaxial films near interfaces, induced by OOC, propagates deeper throughout the films than the tilt angle itself. This allows us to manipulate electronic and magnetic properties in materials over an extensive thickness range, breaking the current limitation of the normally assumed short range of the impact of OOC.

The symmetry of a perovskite is reflected by the characteristic OOR throughout the crystal, which is usually described using Glazer notation [12]. For example, a Glazer notation c’a’a’ corresponds to the orthorhombic Pbnm structure. The Glazer letters hereafter are sequentially corresponding to the rotation about the pseudocubic a, b and c-axes, respectively. For a detailed study of specific OOC effects at interfaces a more precise description of the rotations of each octahedron is required. Therefore, the OOR in a perovskite is patterned into a network of rotation signs of the individual octahedra by defining the clockwise and counterclockwise rotation along specific crystal axes as negative (-) and positive (+) respectively, and no rotation as zero (0), as shown in Fig. 1a. The required connectivity of octahedra strictly restricts the adjacent rotation signs, as illustrated by an example of a single tilt system in the right panel of Fig. 1a, where
adjacent octahedra residing in a plane normal to the tilt axis require opposite rotation signs about that axis. Further, the in-phase or out-of-phase rotation designations restrict the rotation signs of adjacent octahedra along the tilt axis. Therefore, the rotation behavior of each individual octahedron is fully correlated to that of its neighbor by these two octahedral connectivity rules. For a triple octahedral tilt system, the rotation of each individual octahedron has three components of rotation about three pseudocubic axes and the rotation of an octahedron is characterized by three rotation signs, i.e., \((\pm \pm \pm)\), about \(a\), \(b\) and \(c\)-axis respectively (see Fig. 1b). The characteristic Glazer tilt system can be visualized by drawing a rotation signs network of eight octahedra from a unit cell, in which for example a front-bottom-left (FL) octahedron with a specific rotation sign fully determines the whole network. For simplicity, the rotation sign of the front-bottom-left octahedron is used to represent the whole rotation network, e.g., [---] for the bottom rotation signs network in Fig. 1b(I). Disregarding the relative difference in the magnitude of the tilts, the \(c^+a^-a^-\) and \(a^+a^-a^-\) actually have the same rotation pattern and we will focus on the rotation signs network by simplifying the Glazer notation to \(a^+a^-a^-\). There are only two possible rotation networks for \(a^+a^-a^-\): the [---] and the [--+] networks, which correspond to different lattice angles \(\alpha\) (see Supplementary Section I). Taking CaTiO\(_3\) (CTO) as an example, the [---] and [--+] networks produce \(\alpha < 90^\circ\) and \(\alpha > 90^\circ\) respectively [22] (see Fig. 1b(I-II)).

There are two possible resultant structures when coherently growing an orthorhombic perovskite film \((f)\) on an orthorhombic perovskite \((110)_{orth}\) substrate \((s)\): either \([----]/[---]_s\), or \([-++]\)/[---]_s (see Fig. 1b). The interface of \([----]/[---]_s\) naturally maintains an \(a^+a^-a^-\) symmetry across the interface, while \([-++]\)/[---]_s interface violates the two octahedral
connectivity rules mentioned above (For more detail, see Supplementary Fig. S1). To maintain the connectivity of the octahedra, the former is expected to be energetically more favorable, because less octahedral distortion is required to connect the octahedra. Since the symmetry constraints are enforced to every subsequent layer, the symmetry initiated at the interface propagates deeper into the film (see Fig. 1c). This analysis is confirmed experimentally in the study of CTO/NdGaO₃ (NGO) heterostructures, in which CTO [22] and NGO [23] share the same c⁺a⁺a⁻ structure with [---] for α < 90° and [-++] for α > 90°. The unit cell structure of a 30 uc thick CTO film on NGO (110)orth was determined by X-ray reciprocal space mapping (RSM) of the (0-24), (024), (204), (-204) reflections as shown in Fig. 1d. Details of the growth of the films can be found in supplementary Fig. S2 and Table S1. For the orthorhombic c⁺a⁺a⁻ structure, the lattice angles β and γ are 90° and α can be determined as (see Supplementary Fig. S3), yielding for our film αₜₜ = 89.38°. The determined αₜₜ < 90° on α₅₉₉ < 90° structure configuration by RSM suggests that the [---]ο[---]ₜ interface is energetically more favorable than [--+]ο[---]ₜ.

Further strong evidence for OOC mediated symmetry propagation is found in the resultant structure of a SrRuO₃ (SRO) film on a DyScO₃ (DSO) (110)orth substrate. Similar to NGO, the [---] network of DSO corresponds to α < 90° [24], whereas one has α > 90° for the [---] network of SRO [25]. The difference in unit cell tilt directions is caused by the different orthorhombic distortions present (see Supplementary Fig. S4). Therefore, we still expect a [---]ο[---]ₜ growth but with an αₜₜ > 90° on α₅₉₉ < 90° structural configuration for SRO/DSO, which is consistent with experimental observation.
(see Fig. 1e). The RSM of a 30 uc SRO film on DSO shows that $\alpha$ of the SRO film is 90.57°.

In an interface between two perovskites with the same symmetry (homo-symmetric) such as CTO/NGO and SRO/DSO, the OORs can be perfectly matched, hence the resulting OOC effect breaks the mirror symmetry and induces a single domain structure with a single monoclinic tilt direction. In contrast, OORs cannot be matched across an interface between materials with different symmetries (hetero-symmetric), e.g., the interface between rhombohedral ($a^-a^-a^-$) BiFeO$_3$ (BFO) and an orthorhombic ($a^+a^-a^-$) substrate. The BFO has four possible rotation networks: $r_4$ [$---$]$_{\text{rhom}}$, $r_1$ [$+--$]$_{\text{rhom}}$, $r_2$ [$--+]$$_{\text{rhom}}$ and $r_3$ [$+-+$]$_{\text{rhom}}$ [26, 27] all of which have mismatched rotation signs at an interface with a $[---]_{\text{orth}}$ substrate (see Fig. 2a). However, different networks have different degrees of mismatch with $[---]_{\text{orth}}$. The $[---]_{\text{rhom}}$ and $[+--]_{\text{rhom}}$ networks have the same degree of mismatch with the $[---]_{\text{orth}}$ network in that they both have 2 tilt signs violating the first rule at the interface about the $a$-axis, hence the $[---]_{\text{rhom}}$ and $[+--]_{\text{rhom}}$ are equally favored for epitaxial growth. The $[--+]_{\text{rhom}}$ and $[+-+]_{\text{rhom}}$ on $[---]_{\text{orth}}$ also have an equal degree of mismatch and thus are equally favored for epitaxial growth, but they have an additional 4 tilt signs violating the second rule about the $c$-axis besides 2 tilt signs violating the first rule about the $a$-axis. Therefore, the $[---]_{\text{rhom}}/[---]_{\text{orth}}$ and $[+--]_{\text{rhom}}/[---]_{\text{orth}}$ interfaces with less octahedral mismatch are expected to be energetically more favorable than the $[--+]_{\text{rhom}}/[---]_{\text{orth}}$ and $[+-+]_{\text{rhom}}/[---]_{\text{orth}}$ interfaces during growth. Experimentally, the $r_4$ ($[---]_{\text{rhom}}$) and $r_1$ ($[+--]_{\text{rhom}}$) domains indeed are found to be energetically more favorable when BFO films are grown on orthorhombic RESeO$_3$ (RSO) (RE= Dy, Gd, Tb) and SRO (110)$_{\text{orth}}$ substrates [27-29] (see Fig. 2b). The different structure configurations of $\alpha_{\text{BFO}} < 90^\circ$ on
$\alpha_{\text{RSO}} < 90^\circ$ vs $\alpha_{\text{BFO}} < 90^\circ$ on $\alpha_{\text{SRO}} > 90^\circ$ are due to the fact that the RSO and SRO possess $\alpha < 90^\circ$ and $\alpha > 90^\circ$ respectively for the same orthorhombic network. In conclusion, the domain structures of BFO on different orthorhombic substrates are uniformly explained by the OOC mediated symmetry propagation considerations presented above.

If the OOC effect at a hetero-symmetric interface is strong enough to induce a different OOR pattern in a film near the interface to match the substrate OOR, the initiated different symmetry can propagate deeply throughout the film. An example is the structure of a $\text{La}_{2/3}\text{Sr}_{1/3}\text{MnO}_3$ (LSMO) film on an NGO (110)$_{\text{orth}}$ substrate. The bulk LSMO is rhombohedral ($a'a'a'$), but the OOC effect at the LSMO/NGO interface is so strong that one out-of-phase rotation about the $a$-axis in LSMO near the interface (within ~ 3 uc) is converted into in-phase ($a' \rightarrow a^+$) [17]. As a result, the near interface LSMO becomes orthorhombic. Although the effect of OOC on the magnitude of the octahedral tilt decays steeply [17], the characteristic orthorhombic structure still survives over an extensive thickness range, resulting in an orthorhombic structure in thick LSMO films. The RSM of a 30 uc LSMO film shows that the LSMO film possesses an orthorhombic structure with $a'b'c'$ Glazer notation (P$2_1/m$) [15] (see Fig. 3a). The observed $\alpha_{\text{LSMO}} > 90^\circ$ on $\alpha_{\text{NGO}} < 90^\circ$ configuration indicates that the [---]$_{\text{orth}}$ network of LSMO corresponds to $\alpha > 90^\circ$. The $\alpha_{\text{LSMO}} > 90^\circ$ on $\alpha_{\text{NGO}} < 90^\circ$ configuration growth is further microscopically revealed by the scanning transmission electron microscopy (STEM). STEM high angle annular dark field (HAADF) cross-section image shows that the unit cell of LSMO is relatively tilted with respect to the NGO unit cell (see Fig. 3b). The relative tilt angle (defined by $\Delta \alpha$ as shown in the inset of Fig. 3b) is estimated from the B-site positions which are determined using statistical parameter estimation theory [30] (Supplementary Fig. S5). As shown in
the plot of B site (X, Y) positions in Fig. 3c, a sudden change of the slope occurs at the interface which cannot be due to image drift and is therefore ascribed to different monoclinic tilt angles in LSMO and NGO. A relative tilt of \( \Delta \alpha = \tan^{-1}(k_{\text{LSMO}}) - \tan^{-1}(k_{\text{NGO}}) \approx 0.96 \pm 0.06^\circ \) obtained from the STEM image, which agrees well the value of 1\(^\circ\) extracted from RSM (See Fig. 3a and Supplementary Table S2).

The strong impact of the OOC on the symmetry of perovskite heterostructures is further observed when engineering the symmetries through an additional buffer layer. By growing a SrTiO\(_3\) (STO) film, which does not have tilt in its bulk form, on a NGO (110)\(_{\text{orth}}\) substrate, one obtains a STO buffer layer exhibiting a new symmetry of \( a^0a^0c^- \) with \( \alpha = 90^\circ \) (For details, see Supplementary Fig. S6). The LSMO film on this STO buffer layer exhibits a different symmetry from the non-buffered LSMO. According to the RSM of the (024) and (0-24) reflections of the buffered LSMO (see Fig. 3d), (the data of (204) and (-204) for all films mentioned are always symmetric and not shown here), the \( \alpha \) of buffered LSMO becomes 90\(^\circ\), indicating an \( a^0b^+c^- \) (Cmcm) structure. The change of structure due to the STO buffer layer is also atomically visualized in STEM image shown in Fig. 3e, where no relative unit cell tilt exists between LSMO and STO, although it is present at the STO/NGO interface. The relative tilt angle can be calculated using the B-site (X,Y) positions as shown in Fig. 3f. A sudden change of the slope is observed when crossing the STO/NGO interface, due to the tetragonal structure of the STO on the orthorhombic NGO, but is absent at the LSMO/STO interface. The relative tilt angle \( \Delta \alpha \) between LSMO/STO and NGO is about 0.76 \( \pm \) 0.06\(^\circ\), in good agreement with the number obtained from RSM (see Supplementary Table S2). Thus, the mirror symmetry recovered in the STO layer is now transferred into the LSMO layer.
If only considering the strain effect, the LSMO can accommodate the in-plane strain induced by NGO via shaping its structure into either $a^0b^+c^-$ or $a^+b^-c^-$, which both can produce $a < b$ and $\gamma = 90^\circ$ lattice parameters. Since the buffered and non-buffered LSMO share the same strain (see Fig. 3a and 3d), the observed different symmetries of buffered and non-buffered LSMO films on NGO further supports the central role of the OOC mediated symmetry propagation effect in determining the structure of perovskite heterostructures. A similar effect is observed in NdNiO$_3$ (NNO)/STO/NGO (110)$_{\text{orth}}$ (see Fig. 4a) and SRO/STO/DSO (110)$_{\text{orth}}$ (see Supplementary Fig. S6). With an additional STO buffer layer, the orthorhombic NNO and SRO are switched to tetragonal structures. (see Supplementary Table S2). Even in some materials where the intrinsic chemical pressure dominates over epitaxial growth in determining their crystal symmetry, the interfacial OOC effect can still affect the domain structure, e.g., BFO/RESco$_3$ as discussed above and CTO/STO/NGO [see Supplementary Fig. S6].

The OOC is usually considered as an effect to modify the octahedral tilt angle in a very short range of 4-8 uc, however, its long range impact on symmetry has a much more profound impact on the properties of a film. Figure 4b shows the XRD results of 30 uc NdNiO$_3$ (NNO) films on NGO (110)$_{\text{orth}}$ substrates without (NN) and with (NSN) a 6 uc STO buffer layer. The shift in the NNO (002) peak position for NSN as compared to that for NN indicates a larger out-of-plane lattice constant. As a consequence, the metal to insulator transition (MIT) and conductivity of the films are quite different as can be seen in Fig. 4c. The MIT temperature ($T_{\text{MIT}}$) in non-buffered NNO is $\sim 182$ K, similar to previously reported values in bulk and films [31-33], but with a STO buffer layer, the $T_{\text{MIT}}$ is significantly lowered down to $\sim 149$ K. At low temperatures ($T < 150$ K), the
resistivity of the buffered NNO is almost two orders of magnitude less that of non-buffered NNO (see Fig. 4c).

To investigate the impact of this change of symmetry on the electronic and magnetic structure of the NNO films, we performed X-ray absorption spectroscopy (XAS) and resonant magnetic diffraction (RMD) measurements [34]. Figure 5a shows the temperature-dependent Ni L$_3$-edge XAS of the NSN and NN samples. The main features of the XAS—two primary peaks at low temperatures in the insulating regime, which merge together at higher temperatures in the metallic regime—are consistent with previous reports on bulk nickelates [35]. However, the fine details of the two samples are distinctly different. For the STO-buffered film, the two primary peaks are closer together, which is comparatively similar to PrNiO$_3$ (PNO) in the bulk phase diagram [35]. This is consistent with the reduced OOR due to the symmetry imposed by the STO layer. By going from bulk NNO to PNO in the nickelate phase diagram, octahedral rotations are also reduced and the $T_{\text{MIT}}$ shifts to lower temperatures [35], as observed in our symmetry-engineered films.

Figure 5a also shows the energy dependence of the RMD signal at the Ni L$_3$ resonance. The signal arises from the (1/4,1/4,1/4) magnetic Bragg reflection, indicative of the E$'$-type antiferromagnetic ordering of the nickelates. For both films, we find a robust diffraction signal at 22 K, with an energy dependence similar to what has been measured for other nickelates [36,37]. In Fig. 5b, we show the temperature dependence of the RMD signal, with the X-ray energy tuned to that of the L$_3$ resonance maximum. Similar to what was observed for the MIT, we find that the symmetry change imposed by the STO buffer layer reduces the Néel temperature ($T_N$) of the NNO film from 180 K down to ~150 K.
Oxygen K-edge XAS, shown in Fig. 5c, provides a measurement of the Ni-O covalency in the films. The strong pre-peak near 528.5 eV originates from excitations into strongly hybridized Ni 3d – O 2p unoccupied states just above the Fermi level. For the buffered NNO, the pre-peak is wider (FWHM of 1.2 eV versus 1.1 eV as indicated by the arrows for each case) and is pushed to a slightly higher energy, both consistent with a wider bandwidth due to the reduction in OOR for the buffered film. A spectrum from a pure SrTiO$_3$ crystal is shown as well, verifying that a signal from the STO buffer layer does not contribute to the pre-peak region and only adds a small bump at higher energies. The observed increase of the bandwidth due to the STO buffer layer is possibly the driving force [31,35,38] for enhanced conductivity and reduced Néel temperature in the buffered NNO film. Although the exact mechanism for the MIT in NNO films is complex and still a matter of debate [31-39], our finding of the impact of symmetry on $T_{MIT}$ and $T_N$ suggests that the OOR which controls the electron bandwidth could play a vital role [31]. Therefore, the symmetry change imposed by the SrTiO$_3$ buffer layer moves the NNO film significantly across the nickelate phase diagram—as evidenced by the resistivity, magnetism, and general electronic structure—providing a unique and new way of tuning the macroscopic properties.

The control of properties by the engineering of symmetry propagation is found also in LSMO films (For details, see Supplementary Fig. S7). A 6 uc STO buffered 30 uc LSMO film is much more conductive and has higher Curie temperature than a non-buffered LSMO film. Previously reported substrate symmetry effects involving materials such as LSMO [20] or NNO [33] were achieved by using different substrates of NGO (001)$_{orth}$, NGO (110)$_{orth}$, or LSAT (001), where a small difference in lattice mismatch always exists,
hence the effect of strain cannot be fully ruled out. As there is no modification of the strain but solely an engineering of the symmetry of the film, our results unambiguously reveal the strong impact of long range symmetry propagation on properties and functionalities. This long range variation of symmetry enforced by an ultrathin buffer layer also indicates the capability to tailor structure and their properties at unit cell thickness level. Since the octahedral rotation can also cause an octahedral distortion [14], in addition to a change of the octahedral tilt, such control of the symmetry can be used for engineering of magnetic anisotropy [40], orbital ordering [41], ferroelectricity [42] and magnetism [43].

In conclusion, we have illustrated a strong interfacial OOC mediated long range symmetry propagation effect at perovskite oxide interfaces. The symmetry propagation enables us to engineer the symmetry of oxide heterostructures in a flexible way by using either homo-symmetric or hetero-symmetric interfaces. The interfacial OOC initiates symmetry propagating over extensive distances and subsequently allows us to tune the symmetries of epitaxial films by locally varying the substrate symmetry via the insertion of an ultrathin buffer layer. The octahedral network is common in all perovskite heterostructures, hence our findings provide a deep insight into understanding structure-properties relation in perovskite heterostructures and superlattices. The OOC mediated long range symmetry propagation also provides us with a new strategy to engineer structure and functionalities in oxide heterostructure over distances comparable of that of the strain.
Methods:

The perovskite oxide films were grown by pulsed layer deposition (PLD) on single terminated NdGaO$_3$ (110)$_{\text{orth}}$ (NGO) and DyScO$_3$ (110)$_{\text{orth}}$ (DSO) substrates. The single terminated NGO and DSO surfaces were obtained by a combined chemical etching and subsequent high temperature annealing (More details can be found in the Supplementary Information). Reflection high energy electron diffraction (RHEED) was used to accurately control the individual layer thicknesses. Transport properties were characterized by Quantum Design Physics Property Measurement System (QD-PPMS). The lattice structures of the thin films were determined by PANalytical-X'Pert materials research diffractometer (MRD) at high resolution mode. Atomic scale characterization of the lattice structure was performed by Cs-corrected scanning transmission electron microscopy (STEM) on the X-Ant-Em instrument at the University of Antwerp. Cross-sectional cuts of the samples along the NGO [1-10]$_{\text{orth}}$ direction were prepared using a FEI Helios 650 dual-beam Focused Ion Beam device.

The X-ray absorption spectroscopy (XAS) and resonant magnetic diffraction (RMD) were performed using an in-vacuum 4-circle diffractometer at the Resonant Elastic and Inelastic X-ray Scattering (REIXS) beamline at Canadian Light Source (CLS) in Saskatoon, Canada. The beamline has a flux of 5×10$^{12}$ photon/s and photon energy resolution of 10$^{-4}$ eV. The base pressure of the diffractometer chamber was kept lower than 10$^{-9}$ Torr. The XAS spectra were measured using the total fluorescence yield method, with the incident photons at an angle of 30 degrees from the surface. At the Ni L$_3$ edge, π-polarized photons were used (polarization vector within the sample a-c pseudocubic
plane), while at the oxygen K edge, measurements with \( \pi \) and \( \sigma \) polarizations were averaged.

References:


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Author Contributions:


Additional information

Supplementary information is available in the online version of the paper. Reprints and permissions information is available online at www.nature.com/reprints. Correspondence and requests for materials should be addressed to G.K.

Competing financial interest

The authors declare no competing financial interests.
Figure 1: Symmetry propagation initiated at interface. (a) Left, the definition of the rotation sign of an individual octahedron in an ABO$_3$ perovskite unit cell with clockwise (+) and anticlockwise (-); Right, connectivity of octahedra for different rotation sign patterns in a single tilt system. The letters A and B indicate the A-site and B-site atoms respectively. (b) Rotation signs network across CTO/NGO interface. (I) and (II) show the $[-++]_s$ and $[-++]_s$, configurations respectively. The green “$\circ$–$\circ$” highlight some of the matched tilt signs while all the unmatched tilt signs are highlighted by red “$\circ$–$\circ$”. (c) The symmetry constraint shown in (b) is
enforced to every subsequent layer. Green and red arrows indicate the preferred and un-preferred
growth respectively. RSM of (0-24), (024), (204) and (-204) reflections for (d) 30 uc CTO/NGO
and (e) 30 uc SRO/DSO. The film peaks are indicated by arrows and the brightest peaks come
from substrate.
Figure 2: Interfacial OOC induced domain structure of rhombohedral (a’a’a’) BiFeO$_3$ film on orthorhombic (110)$_{\text{orth}}$ substrate. (a) Octahedral rotation signs network at the interface of BiFeO$_3$ and an orthorhombic (110)$_{\text{orth}}$ substrate. The a’a’a’ Glazer tilt system has four different rotation networks [----]$_{\text{rhom}}$, [+--]$_{\text{rhom}}$, [---]$_{\text{orth}}$ and [+--]$_{\text{rhom}}$. The green “ο-ο” highlight some of the matched tilt signs while all the unmatched tilt signs across interface are highlighted by red “ο-ο”.
(b) Domain structures of BiFeO$_3$ films on orthorhombic REScO$_3$ and SrRuO$_3$ (110)$_{orth}$ substrates. Structures adapted from ref. [27-29].
Figure 3: Tailoring structure by interface symmetry engineering. RSM of LSMO films (a) with and (d) without 6 uc STO buffer layers. HAADF cross-section image of 30 uc LSMO films (b) with and (e) without 6 uc STO buffer layers. Inset image at top-right corner of (b) indicates the definition of relative unit cell tilt angle $\Delta \alpha$. (c) The positions (X, Y) of B site atoms from five columns marked by lines in (b). K represents the slope of the curve. (f) The positions (X, Y) of B site atoms from five columns marked by lines in (e).
Figure 4: Manipulating the metal-to-insulator transition in NdNiO$_3$ film. (a) RSM of 6 uc STO buffered 30 uc NNO film on NGO substrate. (b) Theta-2Theta scan of a 30 uc NNO film on NGO without (NN) and with (NSN) a 6 uc STO buffer layer. The arrows indicate the peak position of NNO (002)$_{pc}$. (c) Temperature dependent resistivity of NNO films with and without STO buffer layer. The cooling and warming data are shown by big solid spheres and smaller open circles respectively.
Figure 5: Symmetry tuned electronic structure and antiferromagnetic ordering in NdNiO$_3$ films. (a) Ni L$_3$-edge x-ray absorption (XAS) and resonant magnetic diffraction (RMD) for unbuffered (NN) and STO buffered (NSN) 30 uc NNO on NGO. (b) Temperature dependence of the magnetic diffraction intensity. The arrows indicate the Néel temperature, showing a decrease in the Néel temperature for the buffered film. (c) Oxygen K-edge spectra of the same samples at 300 K, showing an increased bandwidth for the buffered sample.